Wavelength and Bit-rate Tunable Silicon - Organic Hybrid Modulator Using Commercially Available HLD

This work discusses the design of a Si waveguide modulator incorporating a set of 1D Bragg filters using 3 Si-HLD bilayers with a central Si defect region for low voltage tunable Wavelength and variable Bit-rate Modulation.

Arathy krishna, Dr. Prita Nair Shiv Nadar University Chennai

Abstract

In the rapidly advancing field of on-chip photonic modulators, the choice of materials plays a crucial role in achieving highperformance optical modulation. Traditional approaches have utilized nonlinear optical (NLO) material stacks like LiNbO3 or BaTiO3 on silicon substrates or relied on current injection across silicon waveguides to induce phase changes for optical modulation. However, these methods have photostability, thermal stability, and fixed wavelength operation limitations. To address these challenges, this work explores the integration of





Methodology

On application of voltage to the electrodes on either side of the waveguide, the Pockels effect-induced index change of the HLD in the Bragg filter will selectively transmit one wavelength in the C band and one wavelength in the L band. The Refractive index change in the EO material is governed by Equation,



Figure 1 : Design of the Silicon EO Modulator and application

Results

COMSOL Multiphysics software is used to design a silicon HLD waveguide filter. Figure 2 Shows the transmission spectrum for different values of applied voltage and wavelengths in the C(Line graph) & L(Dotted graph) bands. Here, we'll get tuning in both the C and L bands for a single voltage setting. There will be tuning in the C band if the source only covers the C band. One C band and one L band will be transmitted simultaneously if the source is a full broadband source. The desired wavelength of transmission can be changed by applying the proper voltage to the electrodes.

$$\Delta n_{HLD} = -\frac{n_{HLD}^3 \gamma^{33} f^3 V}{2d}$$

Where, Δn_{HLD} is the change in refractive index of HLD , γ^{33} is the EO Coefficient (290 pm/V), V is the applied voltage, d is the separation between electrode, f is the field factor (6.1).



REFERENCES

Resmi, K. S., and Prita Nair. 2017. "Design of a Si-EO Polymer Hybrid WH/TS Encoder with Transformation Optics Based Waveguide Coupler." 2015 Workshop on Recent Advances in Photonics, WRAP 2015, 1–4. <u>https://doi.org/10.1109/WRAP.2015.7806006</u>.

Properties, Physical. 2000. "HLD Is a High Performing Organic Material with Superior Thermal Stability Suitable for Commercial Applications.," 3–6.

Xu, Huajun, Fenggang Liu, Delwin L. Elder, Lewis E. Johnson, Yovan De Coene, Koen Clays, Bruce H. Robinson, and Larry R. Dalton.
2020. "Ultrahigh Electro-Optic Coefficients, High Index of Refraction, and Long-Term Stability from Diels-Alder Cross-Linkable Binary
Molecular Glasses." *Chemistry of Materials* 32 (4): 1408–21. <u>https://doi.org/10.1021/acs.chemmater.9b03725</u>.



Excerpt from the Proceedings of the 2023 COMSOL Conference